# Molecular mechanism and frequency of olorofim resistance in *Aspergillus fumigatus*

Jochem B. Buil<sup>1,2</sup>, Jason Oliver<sup>3</sup>, Derek Law<sup>3</sup>, Marlou Tehupeiory-Kooreman<sup>1,2</sup>, John H. Rex<sup>3</sup>, Margriet W.J. Hokken<sup>1,2</sup>, Willem J.G. Melchers<sup>1,2</sup>, Mike Birch<sup>3</sup>, Paul E. Verweij<sup>1,2</sup>

<sup>1</sup>Department of Medical Microbiology, Radboud University Medical Centre, Nijmegen, the Netherlands, <sup>2</sup>Department of Medical Microbiology and Infectious Diseases, Center of Expertise in Mycology Radboudumc/CWZ, Nijmegen, the Netherlands <sup>3</sup>F2G Ltd, Lankro Way, Manchester, United Kingdom

### Introduction

- Olorofim (OLO) is a **new antifungal agent** with a novel mechanism of action.
- It is active against *Aspergillus fumigatus* both in vitro and in animal models including azole-resistant strains.
- OLO targets dihydroorotate dehydrogenase (DHODH) in the de novo pyrimidine biosynthesis pathway.
- No intrinsic OLO resistance has been detected in surveys to date of >2000 isolates of *A. fumigatus*. However, we observed that resistance could be selected in vitro using a very high inoculum of spores.

#### Objective

In this study, we analysed the frequency of resistance mutation induction of OLO in *A. fumigatus* using two experimental induction methods and using itraconazole (ITZ) as control. Resistant isolates were analysed and the resistance mechanism of OLO in *A. fumigatus* was investigated.

### Results

- Method 1: The **resistance rate** of OLO was 1 in 5 x  $10^7$  (frequency of  $2x10^{-8}$ ) for strain AZN 8196 compared to 1 in 5 x  $10^6$  (2 x  $10^{-7}$ ) for ITZ. For strain V139-36 the resistance rate of OLO was 1 in 9 x  $10^7$  (1.1 x  $10^{-8}$ ) while the **rate for ITZ** was 1 in 8 x  $10^6$  (1.3 x  $10^{-7}$ )
- Method 2: Resistance to OLO in Af293 occurred at a rate of 1 in 6 x  $10^8$  (frequency of 1.7 x  $10^{-9}$ ).
- The phenotype and growth characteristics of OLO-resistant progeny were similar to that of the parent strains for 5 of 6 resistant mutants.
- Sequencing of pyrE revealed a hotspot for resistance mutations in the pyrE-gene for OLO resistance in A. fumigatus at locus Gly119. Four amino acid substitutions were found; G119V, G119C, G119S and G119A. A single OLO-resistant mutant was obtained that carried the wild type DHODH sequence, but this mutant was slow growing compared with the parent strain.

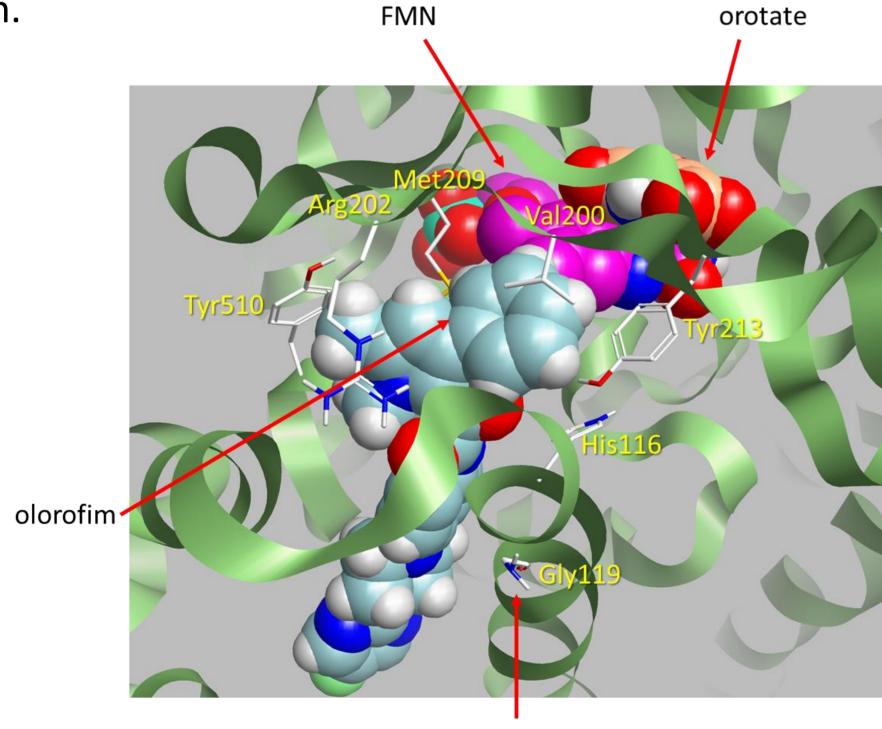


Figure 1: Predicted binding of olorofim to *A. fumigatus* DHODH. Olorofim was docked into a homology model of *A. fumigatus* DHODH. The position of Gly119 is indicated.

## Materials and Methods

The mean rate of OLO resistance induction was calculated for selected isolates and compared with that of ITZ. The *pyrE*-gene, which codes for DHODH, was sequenced for OLO-susceptible parent strains and OLO-resistant progeny isolates and analyzed for mutations.

- Method 1: From two A. fumigatus isolates, AZN 8196 and V139-36, 10 single colonies were separately inoculated onto Sabouraud agar and incubated at 37°C for 96h. From each culture 1 x 10<sup>8</sup> conidia were applied to 6 RPMI agar plates containing either 0.5 mg/L OLO or 8 mg/L ITZ. Plates were incubated at 37°C for up to 7 days. Colonies growing on drug-containing plates were subcultured on RPMI agar containing 0.5 mg/L OLO or 8 mg/L ITZ to confirm resistance.
- Method 2: Spore stocks of *A. fumigatus* **strain Af293** were prepared and inoculated onto yeast nitrogen base with glucose agar (YNBG) containing 0.25 mg/L OLO. A total of 8 x 10<sup>9</sup> spores were inoculated into 12 x 100 ml YNBG-OLO agar plates that were subsequently incubated for 5 days at 35°C. Colonies growing on drug-containing plates were subcultured on YNBG-OLO **to confirm resistance**.

## Discussion and Conclusion

- The OLO resistance rate was 5 to 10-fold lower compared to ITZ, indicating that resistance selection might be less frequent in patients with aspergillosis treated with OLO.
- A hotspot for OLO resistance mutations was identified in the *pyrE*-gene at locus G119.
- Modelling predicts that **Gly119** is on a helix close to the olorofim molecule. Changing the residue at this position potentially affects olorofim binding to DHODH.

#### Conclusion

To date there is a very low frequency of resistance to olorofim seen in clinical isolates of *Aspergillus* spp., and no resistance has been seen in a collection of over 2000 isolates of *A. fumigatus*.

- In vitro we demonstrate that OLO resistance can be selected in A. fumigatus and can be mediated by mutations in the pyrE-gene at locus G119.
- The frequency of resistance varied from approximately 2 x  $10^{-8}$  to 1.7 x  $10^{-9}$  for spontaneous mutations.